FORM PTO-1449/A and B (modified PTO/SB/08)  INFORMATION DISCLOSURE STATEMENT BY APPLICANT				APPLICATION NO.: 10/541,708 ATTY. DO			CKET NO.: A0848.70010US00	
				FILING DATE: July 8, 2005 CONFIRMA			ATION NO.: 6032	
				APPLICANT: Karen Silence				
				GROUP ART UNIT: 1644 EXAMINER		R: Michael Edward Szperka		
Sheet	et 1 of 1			<u> </u>		1		
				U.S.	PATENT DOCUMENTS			
Examiner's Initials <sup>#</sup>	Cite No.	U.S. Patent Docume			Kind Name of Patentee or Applicant of Cited  Code Document		MM-DD-YYYY	
		Number		Code				
		7,771,724		B2	Huizinga et al.		08-10-2010	
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				FOREIG	GN PATENT DOCUMENTS			
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		Office/ Country	Number	Kind Code	Document Cited Document MM-DD-YYYY			(Y/N)
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<sup>#</sup> EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.

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